

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2587	(electrode) near2 (spaced near2 apart) and (microelectronic workpiece wafer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/15 13:57
L2	185	((electrode) near2 (spaced near2 apart)) and (microelectronic workpiece wafer) and (electrolytic electrolytically electroprocess electroprocess\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/15 13:58
L3	246	(abrasive near2 particle) with (micron) and (CMP)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/15 14:29
L5	4	"7101465".pn.	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2009/01/15 14:41
S1	2	"6328872".pn.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:13
S2	9372	((ion adj exchange\$3) (membrane)) and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:35
S3	9372	((ion adj exchange\$3) (membrane)) and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and ((pd<"20030319") (ad<"20030319"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:41

S4	6819	((ion adj exchang\$3) (membrane)) and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and ((@pd<"20030319") (@ad<"20030319"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:45
S5	6819	((ion adj exchang\$3) (membrane)) and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and ((@pd<"20030319") (@ad<"20030319"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:48
S6	6819	((ion adj exchang\$3) (membrane)) and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and ((@pd<"20030319") (@ad<"20030319"))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:48
S7	5546	((ion adj exchang\$3) (membrane)) and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and (@pd<"20030319")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:49
S8	2170	((ion adj exchang\$3) (membrane)) same (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and (@pd<"20030319")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:50

S9	1231	((ion adj exchang\$3) (membrane)) with (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and (@pd<"20030319")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:51
S10	3	((ion adj exchang\$3) (membrane)) with (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and (@pd<"20030319") and (CMP ((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 process process\$3 planariz\$3 planarization)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:52
S11	50	((ion adj exchang\$3) (membrane)) same (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization) and (@pd<"20030319") and (CMP ((chemical chemically) adj (mechanical mechanically) adj (polish polish\$3 process process\$3 planariz\$3 planarization)))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:53
S12	34	((ion adj exchang\$3) (membrane)).clm. and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization).clm. and (@pd<"20030319") and (mechanical CMP mechanically pad slurry).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 11:59

S13	34	((ion adj exchang\$3) (membrane)).clm. and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization).clm. and (@pd<"20030319") and (mechanical CMP mechanically pad slurry).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:00
S14	5	((ion adj exchang\$3) near2 (membrane)).clm. and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization).clm. and (@pd<"20030319") and (mechanical CMP mechanically pad slurry).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:03
S15	0	((ion adj exchang\$3) near2 (membrane)).clm. and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization).clm. and (@pd<"20030319").clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:04
S16	64	((ion adj exchang\$3) near2 (membrane)).clm. and (electrolytic electrolytically electrochemical electrochemically) near3 (process process\$3 polish polish\$3 planariz\$3 planarization).clm. and (@pd<"20030319")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:04
S17	6	((ion adj exchang\$3) near2 (membrane)).clm. and (205/640-686.ccls.)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:06
S18	855	((ion adj exchang\$3) near2 (membrane)).clm. and ("204" "205").clas.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:07

S19	58	((ion adj exchang\$3) near2 (membrane)).clm. and ("204" "205").clas. and (polish polish\$3 planariz\$3 planarization)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:07
S20	353	((ion adj exchang\$3) catalyst (pure adj water)).clm. and ("204" "205").clas. and (polish polish\$3 planariz\$3 planarization)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:21
S21	23	((ion adj exchang\$3) catalyst (pure adj water)).clm. and ("204" "205").clas. and (polish polish\$3 planariz\$3 planarization) with (pure adj water)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:21
S22	243	((ion adj exchang\$3) catalyst (pure adj water)).clm. and (polish polish\$3 planariz\$3 planarization) with (pure adj water)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:22
S23	100	((ion adj exchang\$3) catalyst (pure adj water)).clm. and (polish polish\$3 planariz\$3 planarization process process \$3) with (pure adj water) and (electrolytic electrolytically electrochemical electrochemically) near2 (polish polish\$3 planariz\$3 planarization process process \$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:23
S24	47	((ion adj exchang\$3) catalyst (pure adj water)).clm. and (polish polish\$3 planariz\$3 planarization process process \$3) with (pure adj water) and ((electrolytic electrolytically electrochemical electrochemically) near2 (polish polish\$3 planariz\$3 planarization process process \$3)).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:24

S25	100	((ion adj exchang\$3) catalyst (pure adj water)).dm. and (polish polish\$3 planariz\$3 planarization process process \$3) with (pure adj water) and ((electrolytic electrolytically electrochemical electrochemically) near2 (polish polish\$3 planariz\$3 planarization process process \$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:24
S26	157	((ion adj exchang\$3) catalyst) and (pure adj water) and (polish polish\$3 planariz \$3 planarization process process\$3) with (pure adj water) and ((electrolytic electrolytically electrochemical electrochemically) near2 (polish polish\$3 planariz\$3 planarization process process \$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 12:25
S27	4	"2002047139"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 13:14
S28	6	2002-126400	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 14:05
S29	2	"2002126400"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 14:05
S30	6	"2002012640"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 14:06
S31	15	2002-000838	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 14:06

S32	3	"20030132103"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/05/26 14:10
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